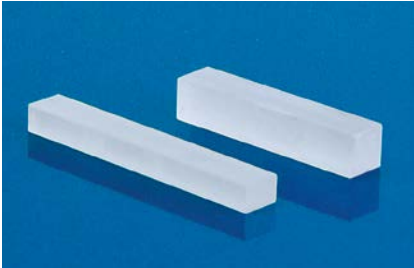


Nonlinear Crystals

LBO – LITHIUM TRIBORATE



LBO is well suited for various nonlinear optical applications:

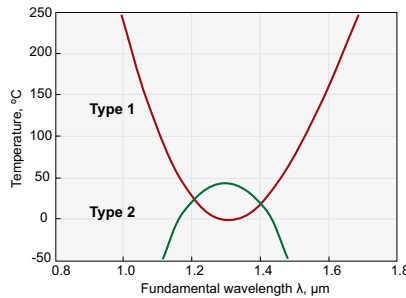
- › frequency doubling and tripling of high peak power pulsed Nd doped, Ti:Sapphire and Dye lasers
- › optical parametric oscillators (OPO) of both Type 1 and Type 2 phase-matching
- › non-critical phase-matching for frequency conversion of CW and quasi-CW radiation.

STANDARD SPECIFICATIONS

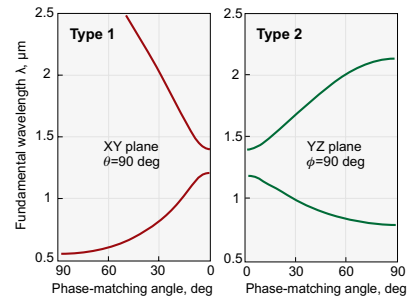
| | |
|--------------------|---------------------------------------|
| Flatness | $\lambda/8$ at 633 nm |
| Parallelism | < 20 arcsec |
| Surface quality | 10 – 5 scratch & dig (MIL-PRF-13830B) |
| Perpendicularity | < 5 arcmin |
| Angle tolerance | < 30 arcmin |
| Aperture tolerance | ± 0.1 mm |
| Clear aperture | 90% of full aperture |

FEATURES

- › Wide transparency region
- › Broad Type 1 and Type 2
- › Non-critical phase-matching (NCPM) range
- › Small walk-off angle
- › High damage threshold
- › Wide acceptance angle
- › High optical homogeneity



NCPM SHG temperature dependence of LBO



SHG tuning curves of LBO

WE OFFER:

- › Crystals length up to 90 mm and aperture up to 60 x 60 mm
- › AR, BBAR, P-coatings
- › Different mounting and repolishing services

STANDARD CRYSTALS LIST

| Size, mm | θ , deg | ϕ , deg | Coating | Application | Catalogue number | Price, EUR |
|----------|----------------|--------------|-------------------------|--------------------------------|------------------|------------|
| 3x3x10 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-401 | 245 |
| 3x3x15 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-402 | 325 |
| 4x4x10 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-301 | 510 |
| 4x4x15 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-302 | 630 |
| 4x4x20 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-303 | 745 |
| 5x5x10 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-501 | 655 |
| 5x5x15 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-503 | 765 |
| 5x5x20 | 90 | 11.6 | AR/AR @ 1064+532 nm | SHG @ 1064 nm | LBO-502 | 940 |
| 3x3x15 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-404 | 325 |
| 3x3x20 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-405 | 405 |
| 3x3x30 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-409 | 710 |
| 3x3x50 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-410 | 1300 |
| 4x4x10 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-304 | 510 |
| 4x4x15 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-305 | 630 |
| 4x4x20 | 90 | 0 | AR/AR @ 1064+532 nm | NCPM SHG @ 1064 nm, T = 149 °C | LBO-306 | 745 |
| 3x3x10 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-406 | 245 |
| 3x3x15 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-407 | 325 |
| 4x4x10 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-307 | 510 |
| 4x4x15 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-308 | 630 |
| 5x5x10 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-507 | 655 |
| 5x5x15 | 42.2 | 90 | AR/AR @ 1064+532/355 nm | THG @ 1064 nm | LBO-508 | 765 |

PHYSICAL AND OPTICAL PROPERTIES

| | | | |
|--|---|--------|--------|
| Chemical formula | LiB ₃ O ₅ | | |
| Crystal structure | orthorhombic, mm2 | | |
| Optical symmetry | Negative biaxial | | |
| Space group | Pna2 ₁ | | |
| Density | 2.47 g/cm ³ | | |
| Mohs hardness | 6 | | |
| Optical homogeneity | $\partial n = 10^{-6} \text{ cm}^{-1}$ | | |
| Transparency region at "0" transmittance level | 155 – 3200 nm | | |
| Linear absorption coefficient at 1064 nm | < 0.01 % cm ⁻¹ | | |
| Refractive indices: | n_x | n_y | n_z |
| at 1064 nm | 1.5656 | 1.5905 | 1.6055 |
| at 532 nm | 1.5785 | 1.6065 | 1.6212 |
| at 355 nm | 1.5971 | 1.6275 | 1.6430 |
| Sellmeier equations ($\lambda, \mu\text{m}$) | $n_x^2 = 2.4542 + 0.01125 / (\lambda^2 - 0.01135) - 0.01388 \lambda^2$ $n_y^2 = 2.5390 + 0.01277 / (\lambda^2 - 0.01189) - 0.01849 \lambda^2 + 4.3025 \times 10^{-5} \lambda^4 - 2.9131 \times 10^{-5} \lambda^6$ $n_z^2 = 2.5865 + 0.0131 / (\lambda^2 - 0.01223) - 0.01862 \lambda^2 + 4.5778 \times 10^{-5} \lambda^4 - 3.2526 \times 10^{-5} \lambda^6$ | | |
| Phase matching range Type 1 SHG | 554 – 2600 nm | | |
| Phase matching range Type 2 SHG | 790 – 2150 nm | | |
| NCPM SHG temperature dependence: | | | |
| Type 1 range 950 – 1300 nm | T1 = - 1893.3 λ^4 + 8886.6 λ^3 - 13019.8 λ^2 + 5401.5 λ + 863.9 | | |
| Type 1 range 1300 – 1800 nm | T2 = 878.1 λ^4 - 6954.5 λ^3 + 20734.2 λ^2 - 26378 λ + 12020 | | |
| Type 2 range 1100 – 1500 nm | T3 = - 21630.6 λ^4 + 112251 λ^3 - 220460 λ^2 + 194153 λ - 64614.5 | | |
| NCPM SHG at 1064 nm Type 1 temperature | 149 °C | | |
| NCPM SHG at 1319 nm Type 2 temperature | 43 °C | | |
| Walk-off angle | 7 mrad (Type 1 SHG 1064 nm) | | |
| Thermal acceptance | 6.4 Kxcm (Type 1 SHG 1064 nm) | | |
| Angular acceptance | 6.5 mradxcm (Type 1 SHG 1064 nm) 248 mradxcm (Type 1 NCPM SHG 1064 nm) | | |
| Nonlinearity coefficients | $d_{31} = - (0.98 \pm 0.09) \text{ pm/V}$; $d_{32} = (1.05 \pm 0.09) \text{ pm/V}$; $d_{33} = (0.05 \pm 0.006) \text{ pm/V}$ | | |
| Effective nonlinearity: | | | |
| XY plane | $d_{\text{ooe}} = d_{32} \cos\phi$ | | |
| YZ plane | $d_{\text{eoo}} = d_{\text{eoo}} = d_{31} \cos\theta$ | | |
| Expansion coefficients | $\alpha_x = 10.8 \times 10^{-5} \text{ K}^{-1}$; $\alpha_y = - 8.8 \times 10^{-5} \text{ K}^{-1}$; $\alpha_z = 3.4 \times 10^{-5} \text{ K}^{-1}$ | | |
| Laser induced damage threshold (LIDT) | > 5 J/cm ² (> 500 MW/cm ²), 1064 nm, 10 ns, 10 Hz | | |

Please contact EK SMA OPTICS for further information or nonstandard specifications.

RELATED PRODUCTS

LBO crystals for SHG of Yb:KGW/KYW laser frequency conversion. See page 4.42

Crystal Oven TC2
See page 2.28



149 °C temperature is required to achieve Non-Critical Phase Matching (NCPM) in LBO at type 1 SHG of 1064 nm application. **TC2 oven** is specially designed for this purpose (see technical specifications, p. 2.28).

Heatpoint
Crystal Oven
See page 2.29



Heatpoint is a compact round oven designed for heating (30 – 80 °C) of humidity sensitive nonlinear crystals. It is used to prevent moisture condensation on crystal faces or for thermostabilization of the crystals.